



國立交通大學

National Chiao Tung University

# 清華大學物理系 奈米物理特論 2009/11/19 上課內容 (I)

## 半導體奈米結構之成長與光電特性

交通大学電子物理系 周武清 教授

大綱:

Part I: 半導體奈米結構成長-----

分子束磊晶(MBE, molecular beam epitaxy)

半導體奈米結構形貌研究---AFM

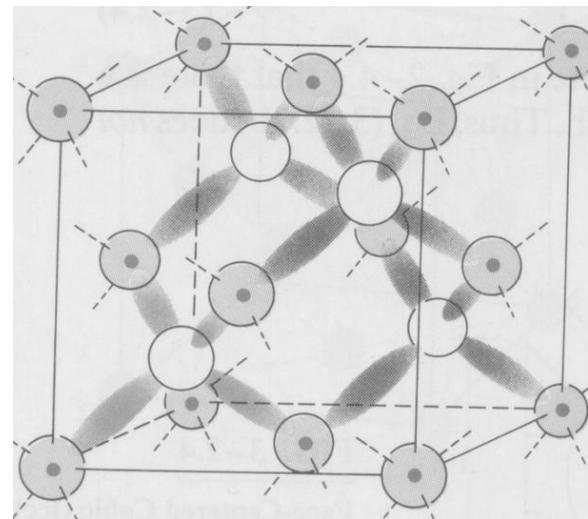
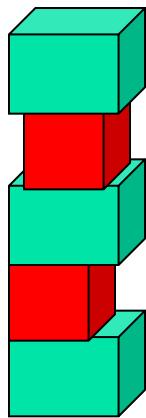
Part II: 半導體奈米結構光電特性---Photoluminescence

Part III: 半磁性半導體奈米結構之自旋磁光特性



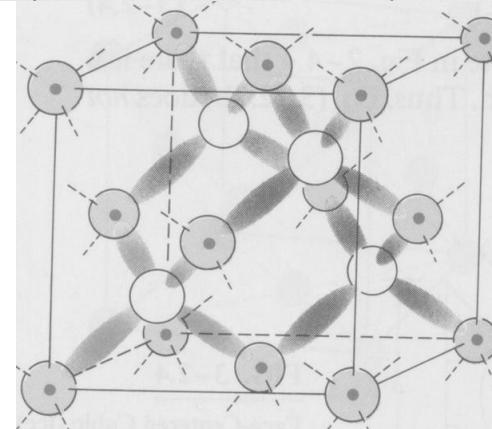
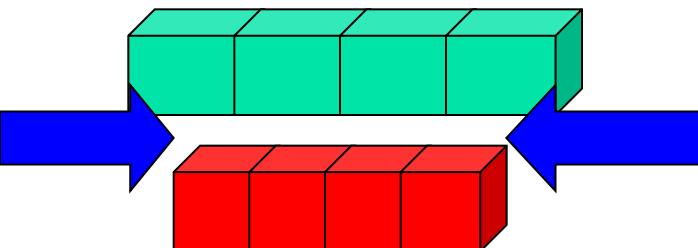


# Hetero-structure epitaxy 異質結構磊晶



● Zn  
○ Te  
 $E_g=2.4\text{ V}$

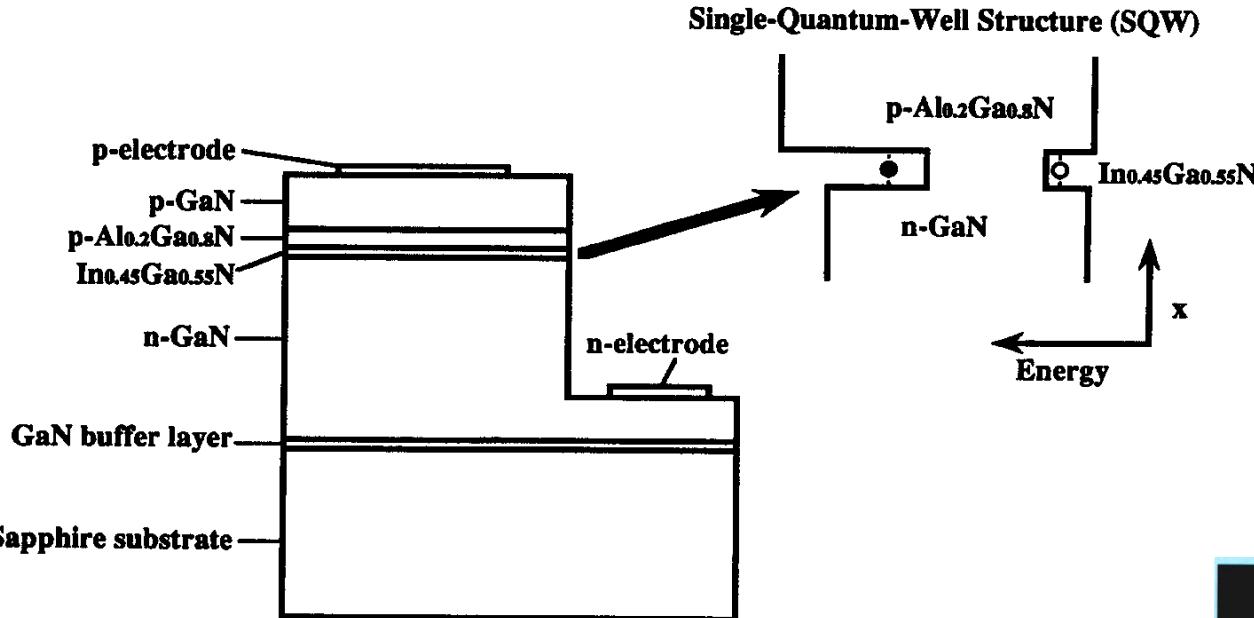
Compressive strain 壓縮應變



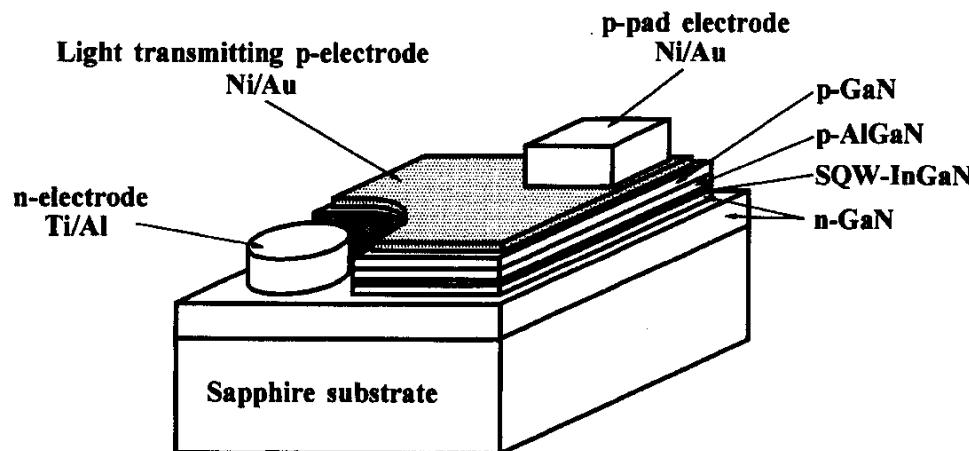
● Zn  
○ Se  
 $E_g=2.8\text{ V}$

原子排列與堆疊 魔術師:操控晶格常數 能隙等

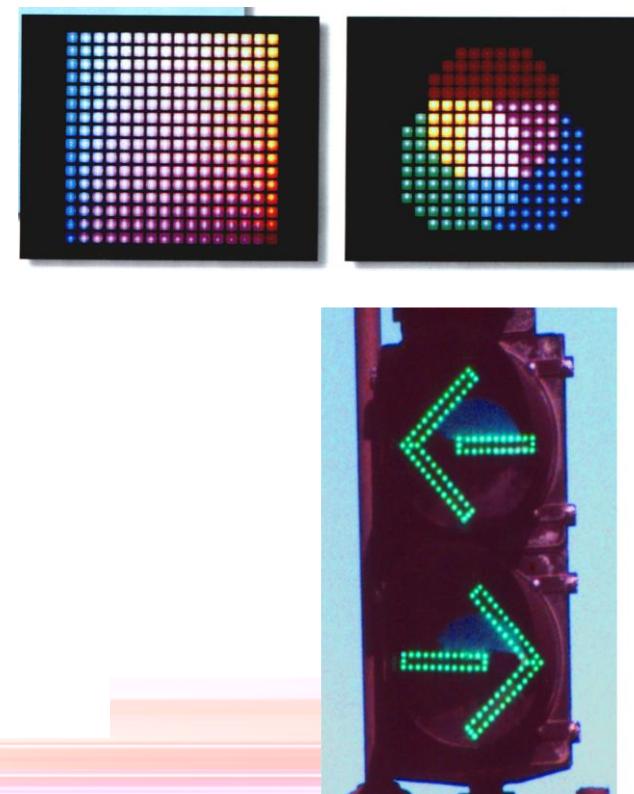
## *InGaN green SQW LEDs*



The structure of a green SQW LED

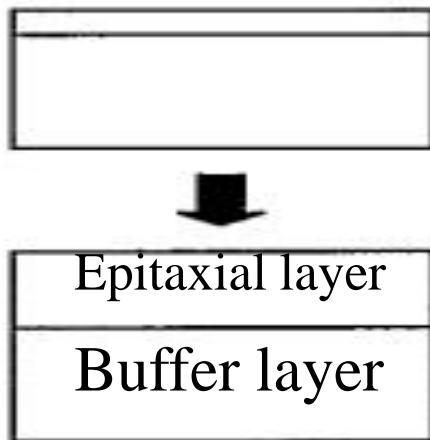


Schematic drawing of the SQW LED



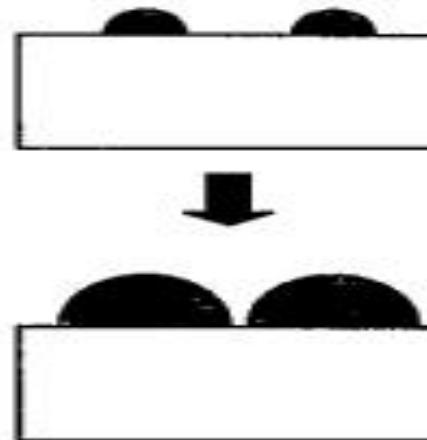
# Self-assembled nanostructures, Self-organized quantum dots (QDs)

自聚性量子點

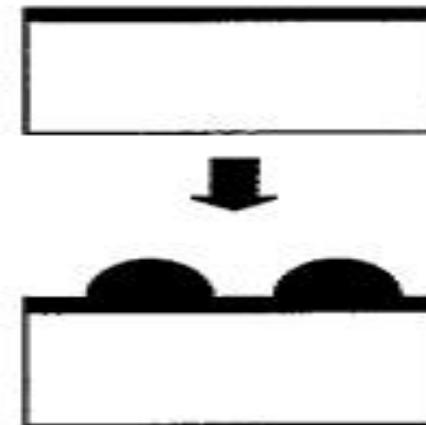


**F-vdM**

Frank-van der Merwe  
二維長晶模式



Volmer-Weber (VW)  
三維長晶模式



Stranski-Krastanow (SK)從二維到  
三維長晶模式(**wetting layer, WL**)

$$u(H, n_1, n_2, \epsilon) = E_{\text{ml}}(n_1) + n_2 E_{\text{isl}} + (H - n_1 - n_2) E_{\text{rip}}$$

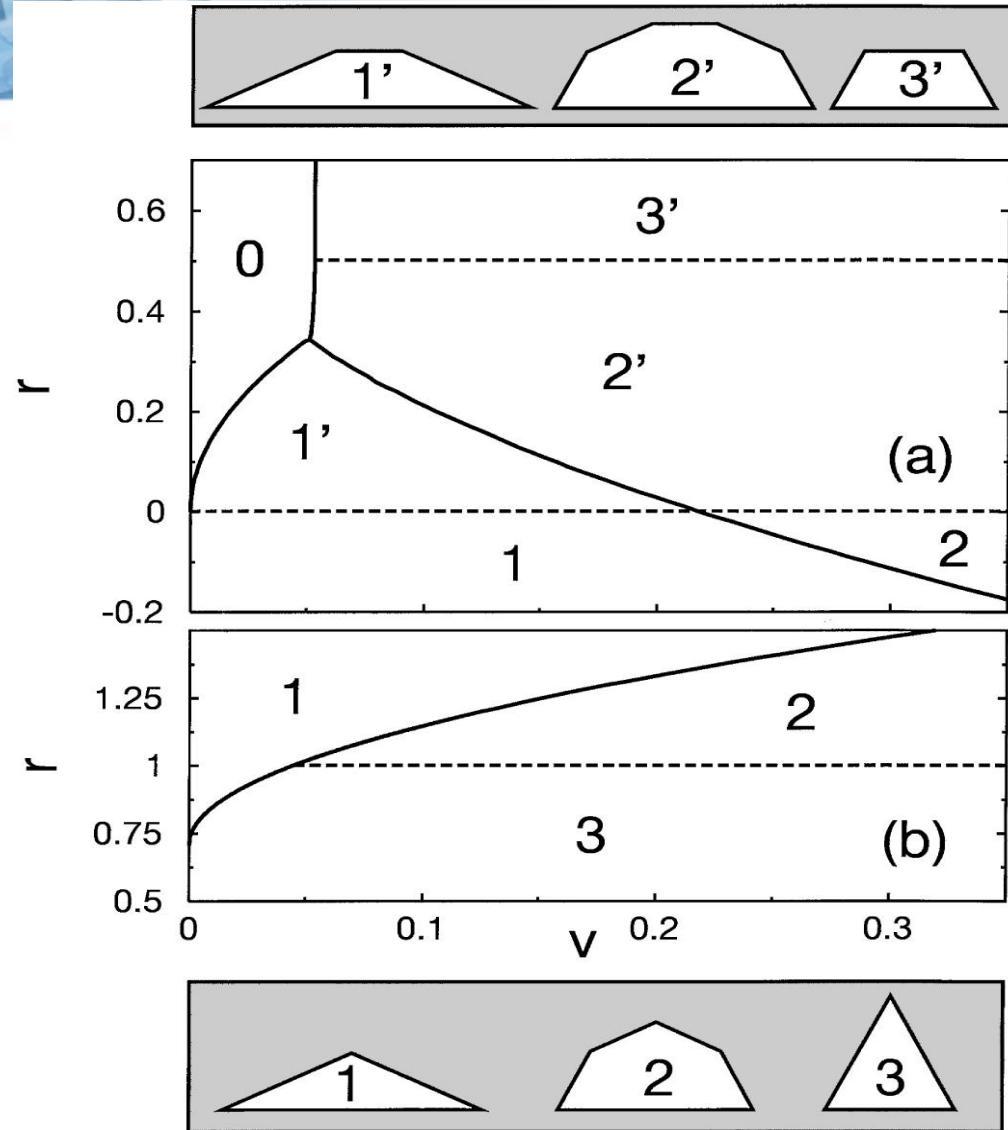
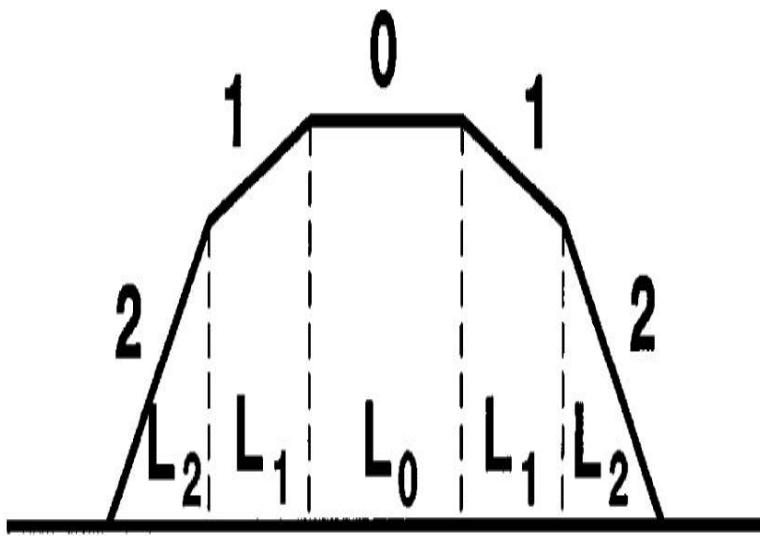
$$E_{\text{ml}}(n_1) = \int dn \left\{ G + \Delta [\Theta(1-n) + \Theta(n-1) e^{-(n-1)/a}] \right\}$$

$$G = C\epsilon^2 - \Phi_{AA}$$

$$E_{\text{isl}} = gC\epsilon^2 - \Phi_{AA} + E_0 [ -(2/x^2) \ln e^{1/2} x + \alpha/x + \beta(n_2)/x^{3/2} ]$$

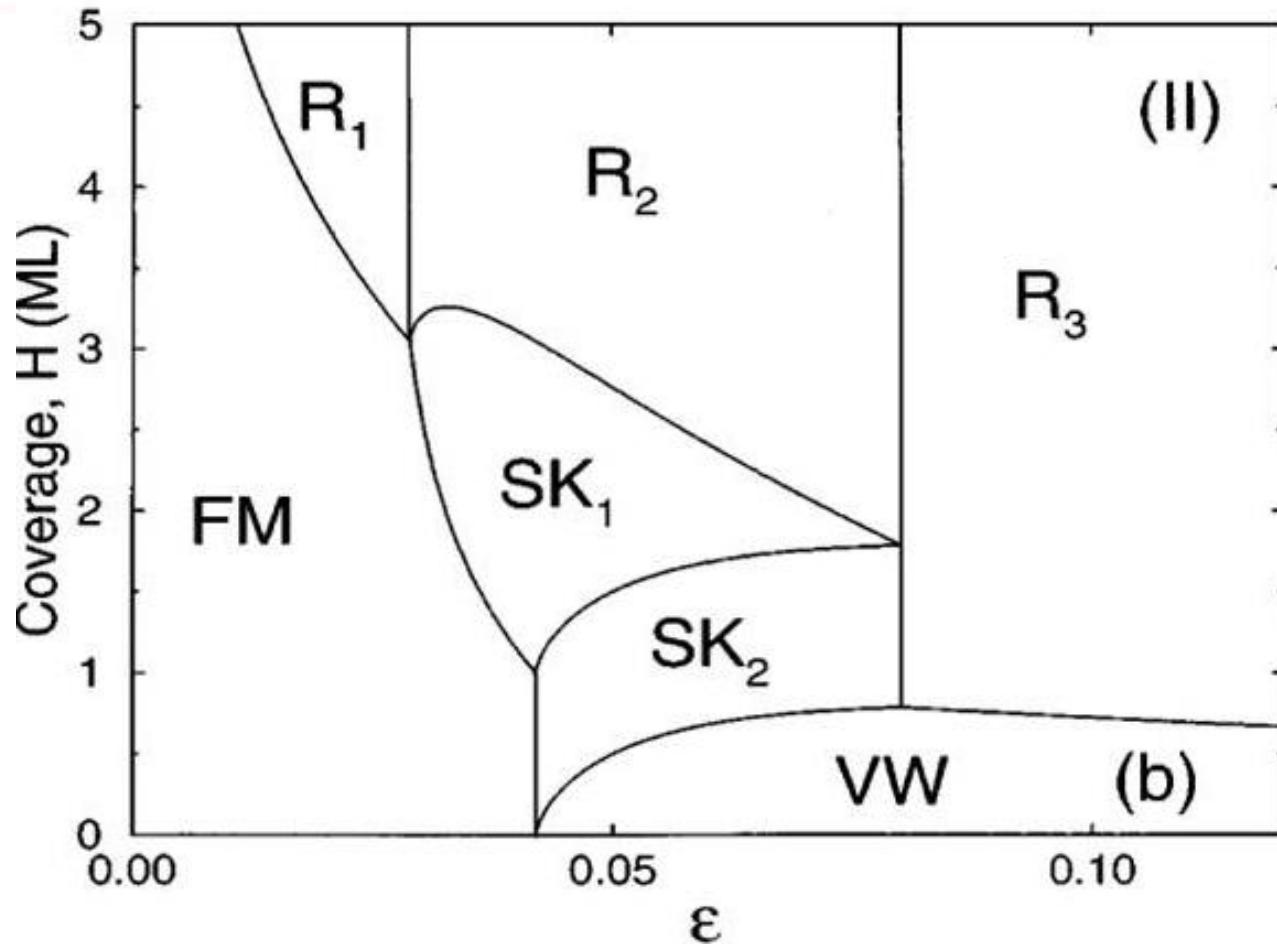
$$E_{\text{rip}} = E_{\text{isl}}(x \rightarrow \infty) = gC\epsilon^2 - \Phi_{AA}$$

D.J. Eaglesham and M. Cerullo,  
PRL 64, 1943 (1990)



**Key:** strained islands change shape during growth, phase diagram, surface energy controls the sequence of island shapes.

I Daruka et al., PRL 82, 2753 (1999)



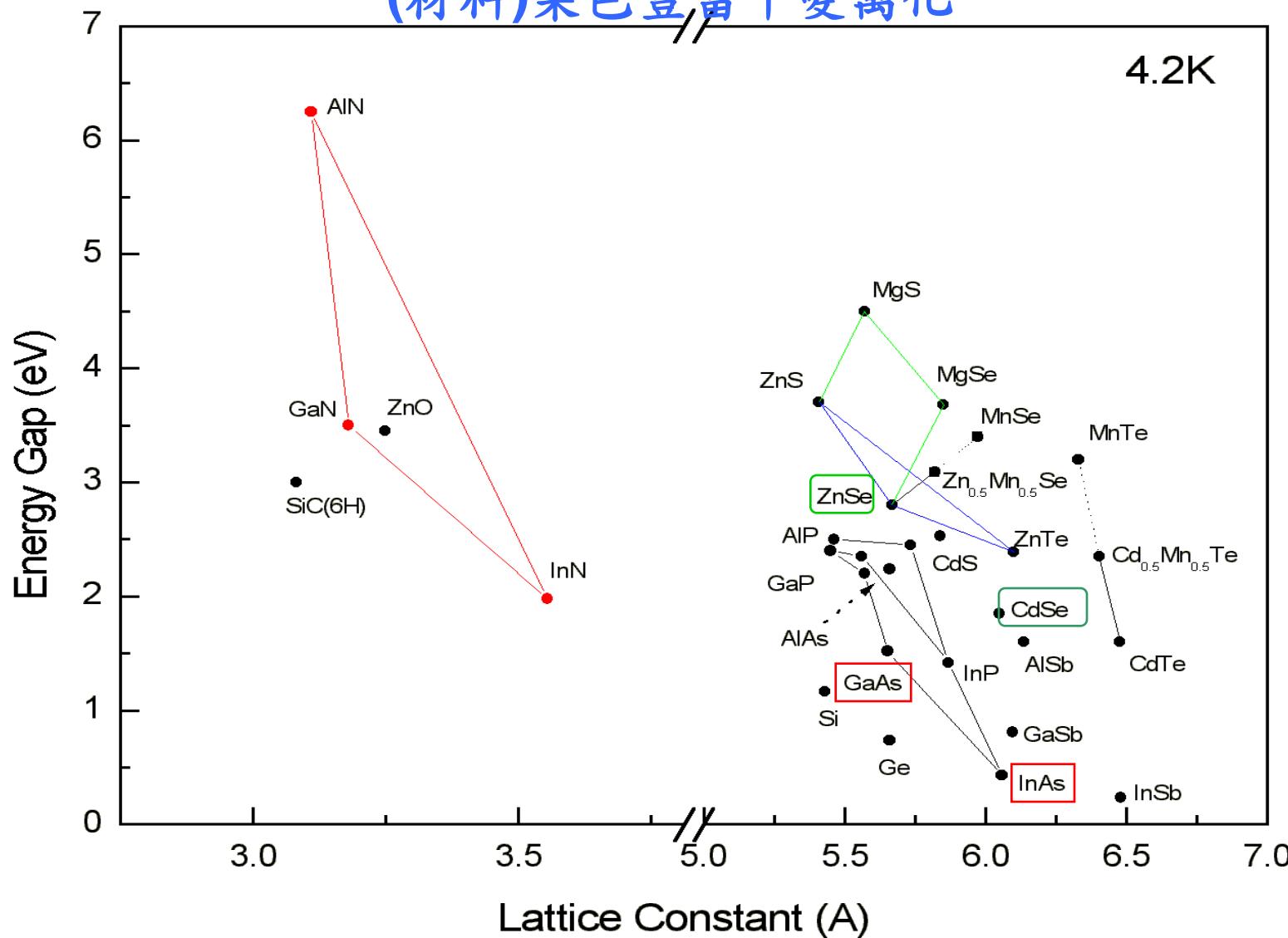
$$u(H, n_1, n_2, \epsilon) = E_{\text{ml}}(n_1) + n_2 E_{\text{isl}} + (H - n_1 - n_2)E_{\text{rip}}$$

- I. Daruka and A.L. Barabasi, APL 72, 2102 (1998)



# Energy Gap vs Lattice Constant

(材料) 菜色豐富千變萬化



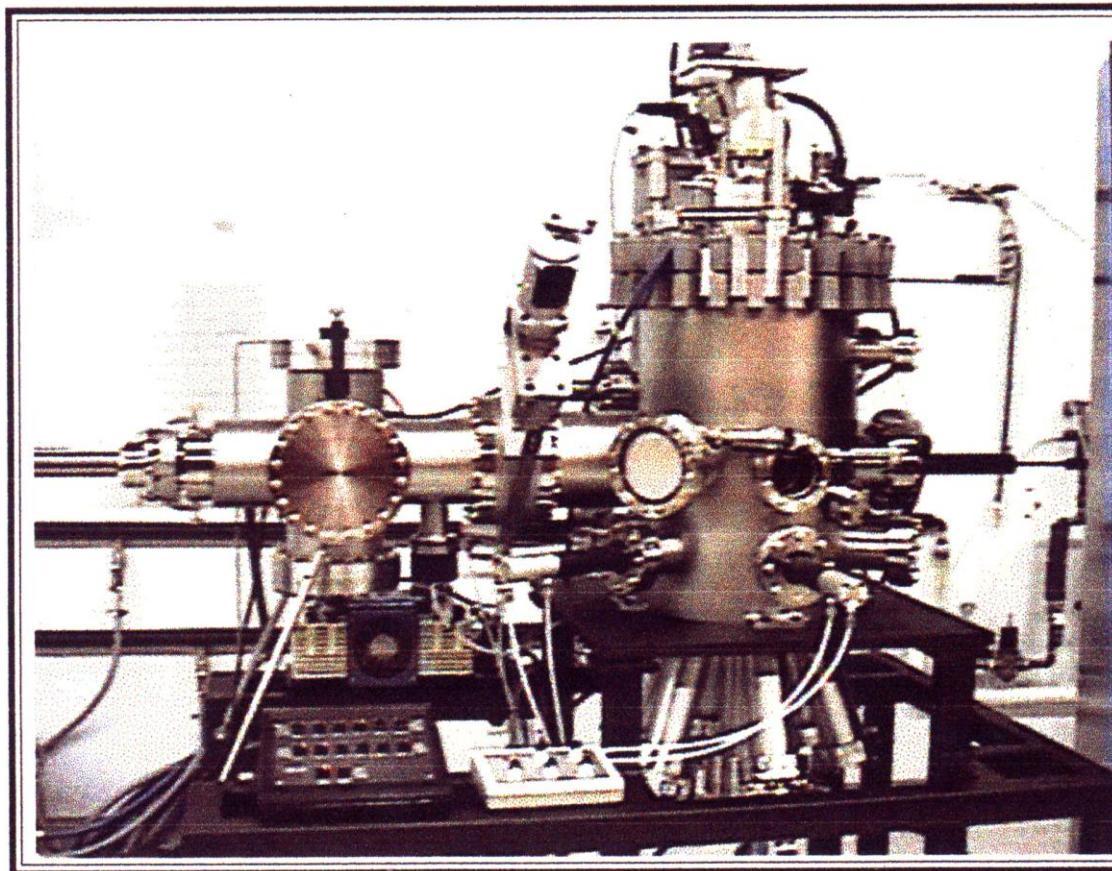


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如何製作半導體奈米結構?

**EPI  
Model 620  
Molecular Beam Epitaxy System**



Rev Date: 11/96

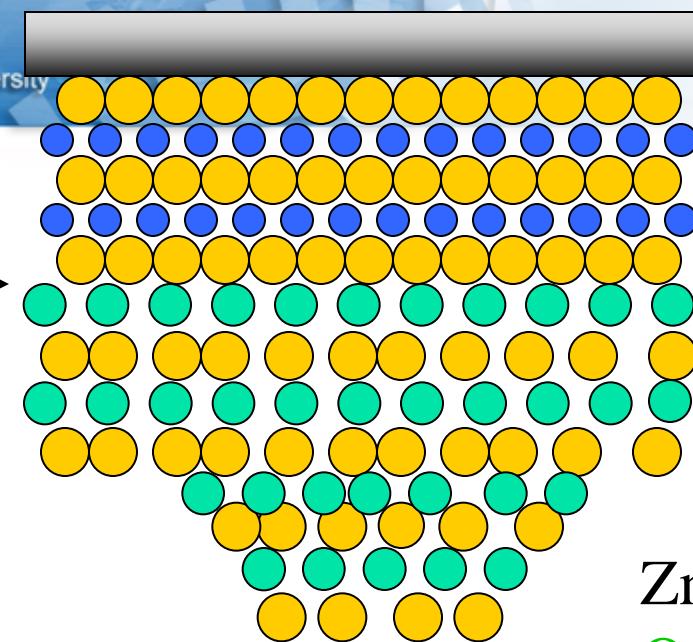
超高真空操作程序與重要性、分子束源種類及調控磊晶速率



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Alternating supply MBE



substrate

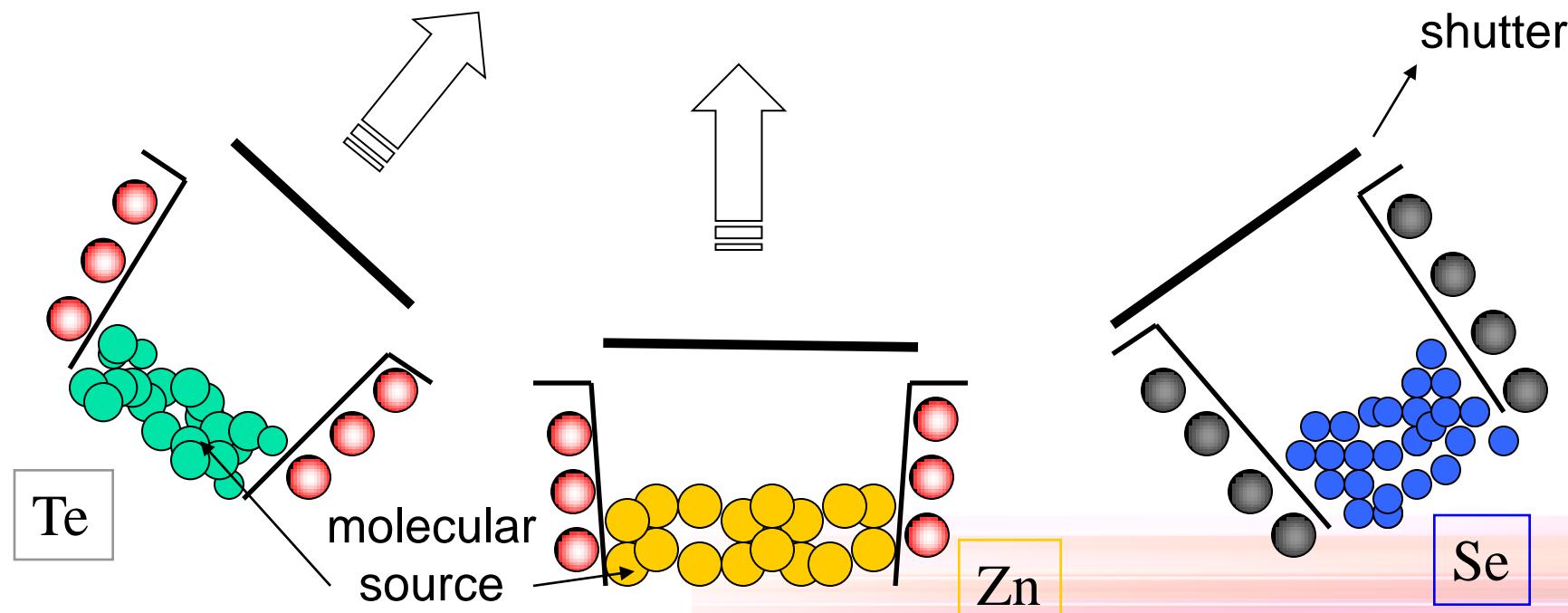
buffer ZnSe

strain

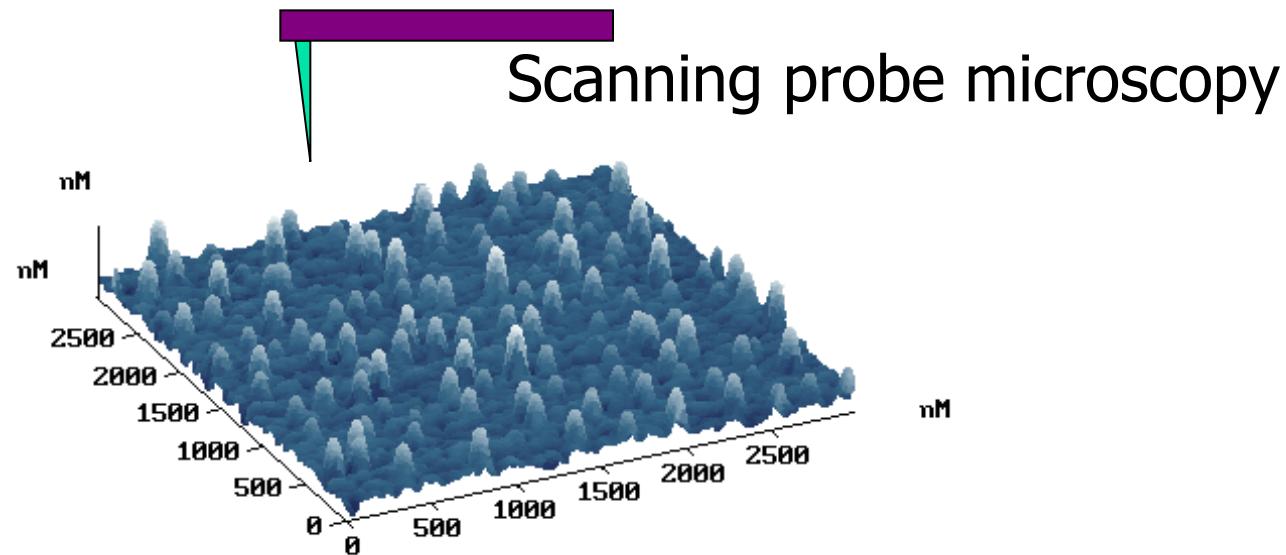
ZnTe or CdSe  
Wetting layer

ZnTe or CdSe  
Quantum Dot

Atomic Layer Epitaxy  
(ALE)



# Atomic force microscopy, AFM



1982 IBM蘇黎世研究所的Gerd Binnig和Heinrich Rohrer及其同事研製第一臺達到原子分辨解析度的表面分析儀器，掃描穿隧顯微鏡(Scanning Tunneling Microscope, STM)。1986 G. Binnig和同事發明原子力顯微鏡(Atomic Force Microscopy, AFM)。(Note:scanning, computer control bit)  
**Scanning probe microscopy (SPM), SNOM**

The Nobel Prize in Physics 1986

"for their design of the scanning tunneling microscope"

**Gerd Binnig**



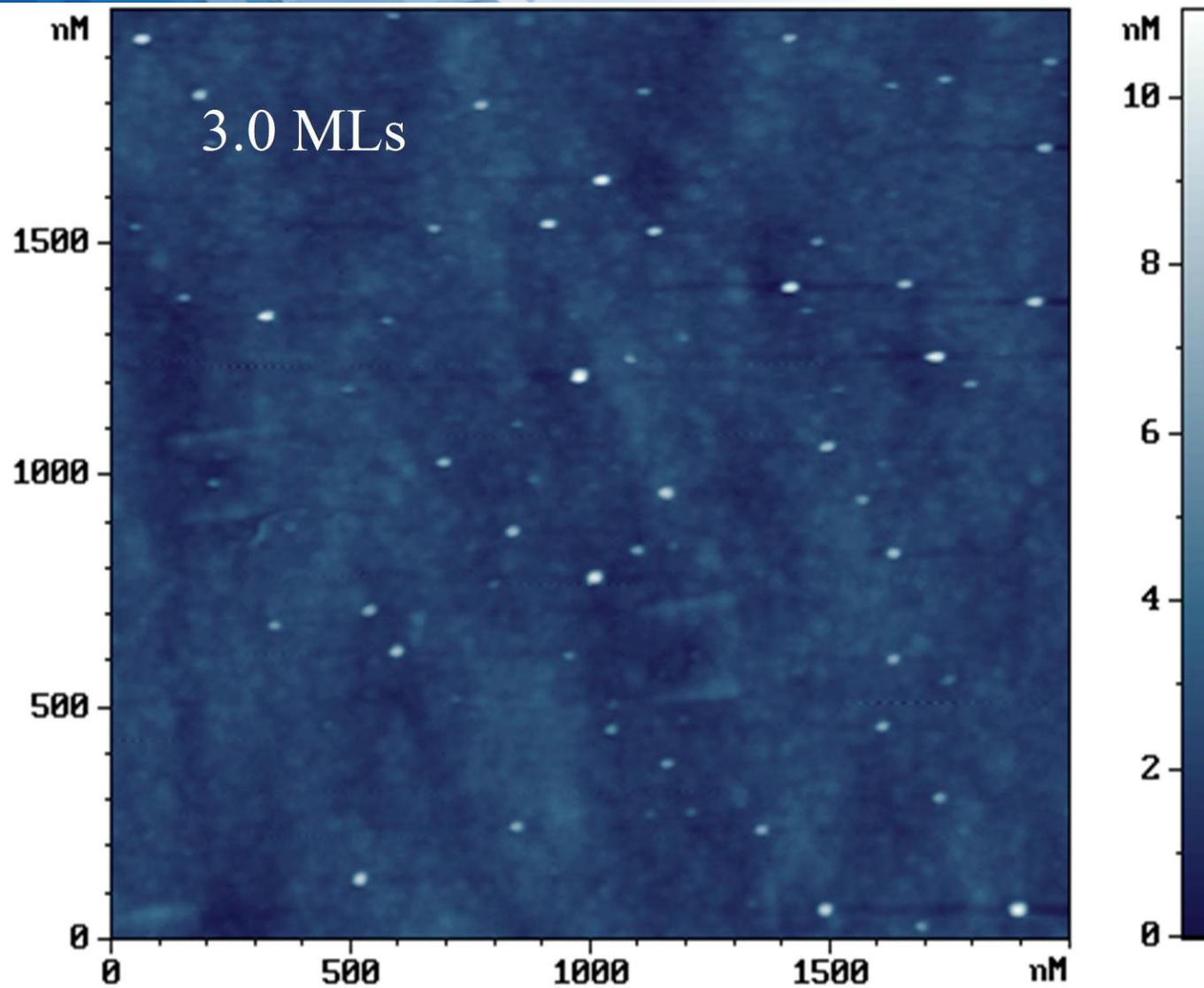
**Heinrich Rohrer**





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碲化鋅量子點之表面高低(明暗)形貌直徑約10-30奈米

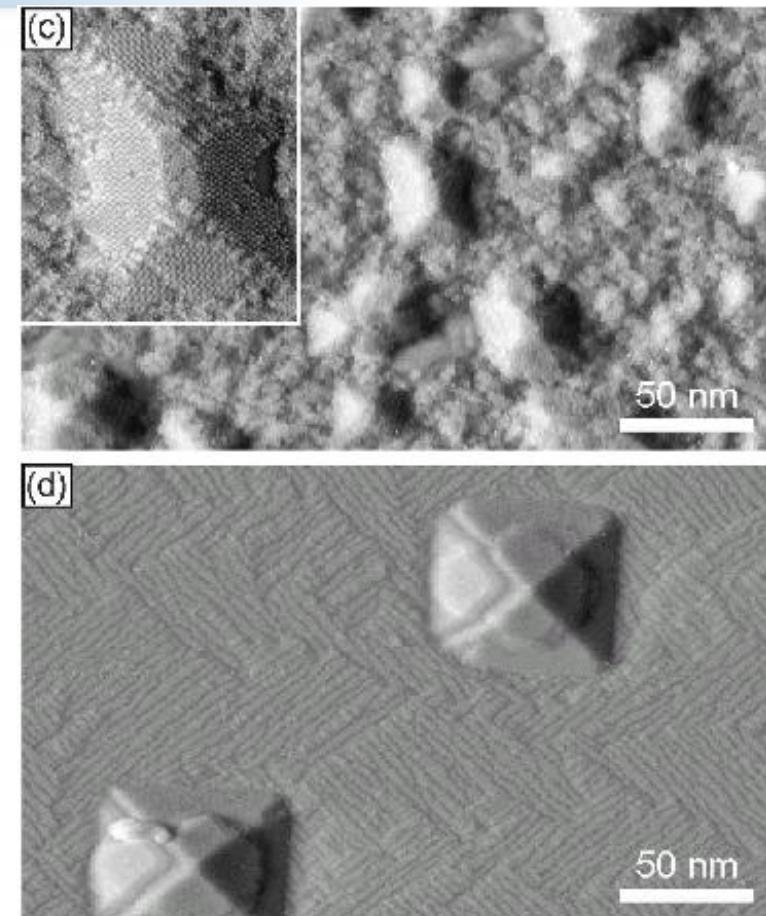
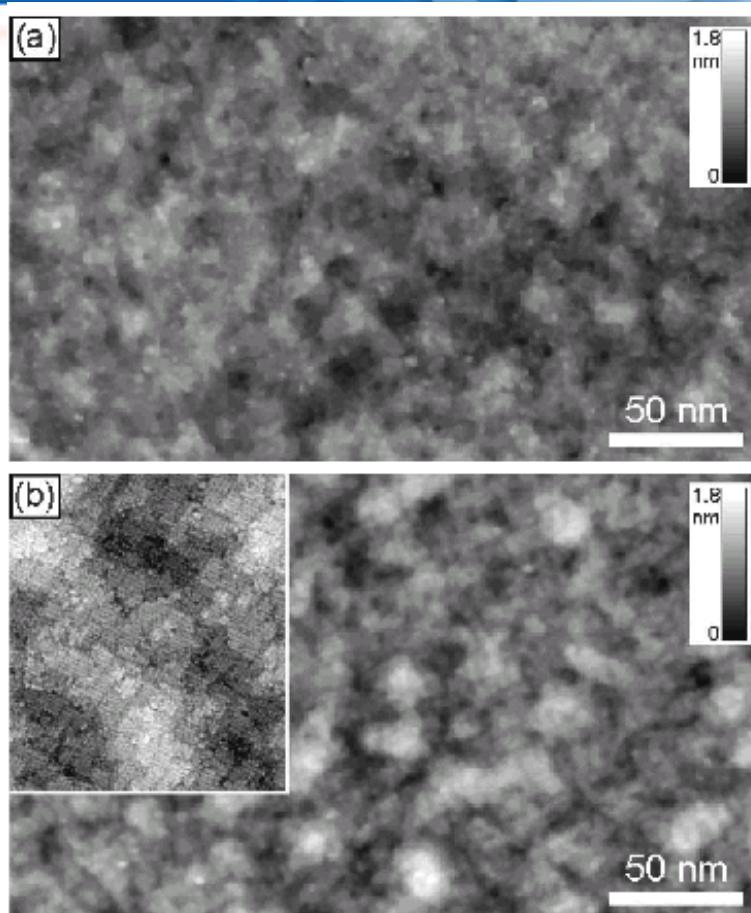
AFM



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半導體奈米結構之形狀



***In situ* scanning tunneling microscopy study of C-induced Ge quantum dot formation on Si(100)**

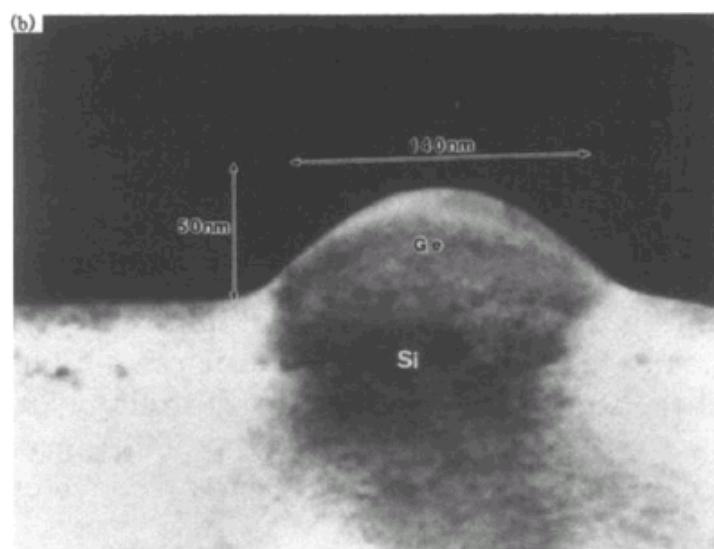
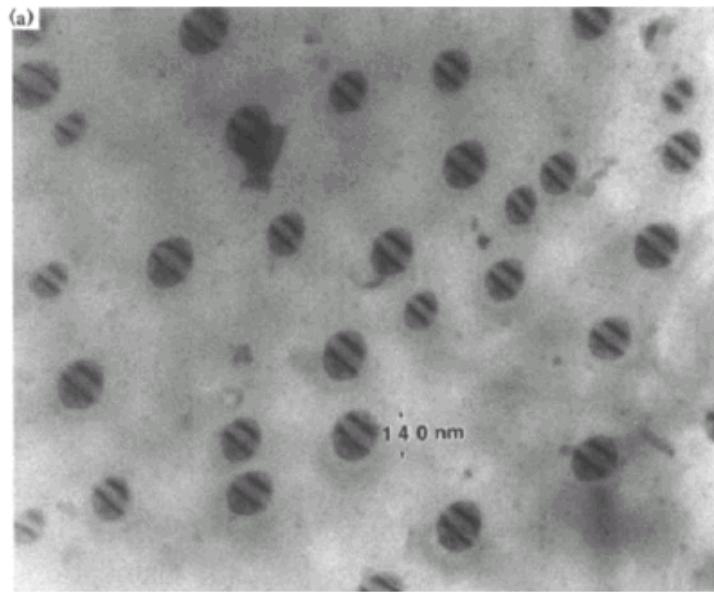
O. Leifeld et al., APL74, 994 (1999)



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# Dislocation-Free Stranski-Krastanow Growth of Ge on Si(100)



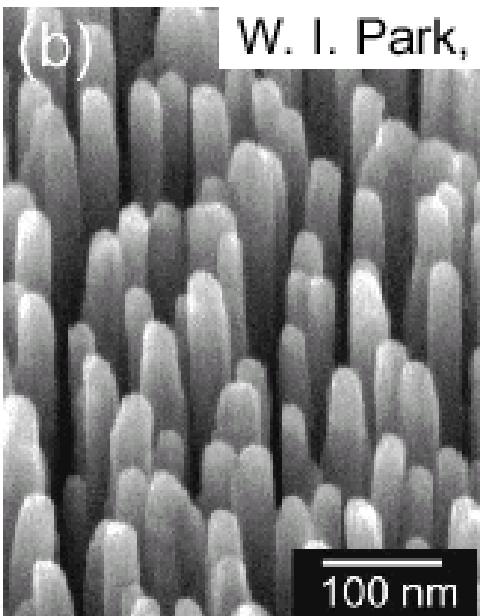
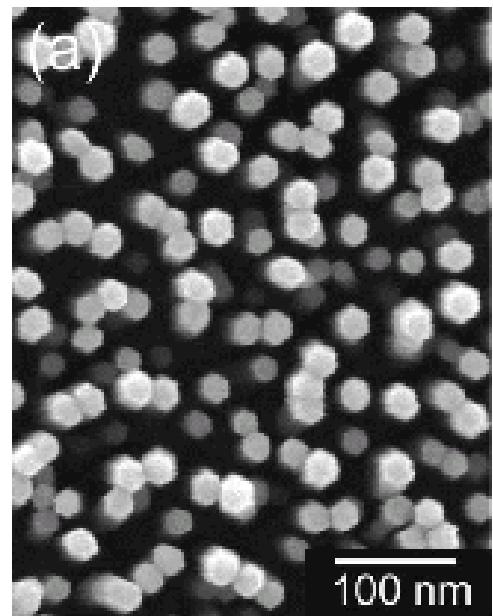
D. J. Eaglesham and M. Cerullo

PRL64, 1943 (1990)

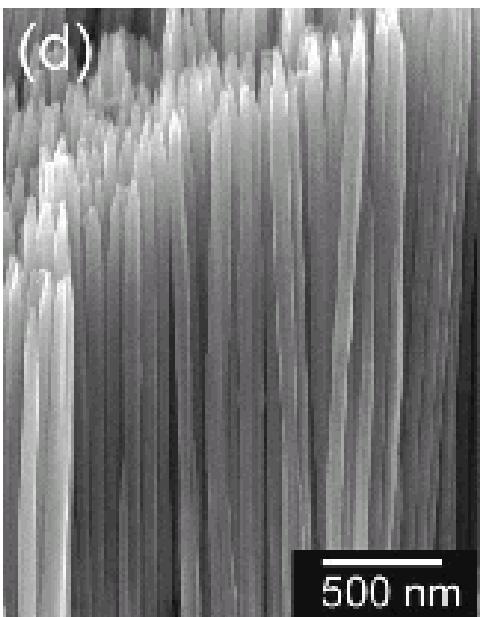
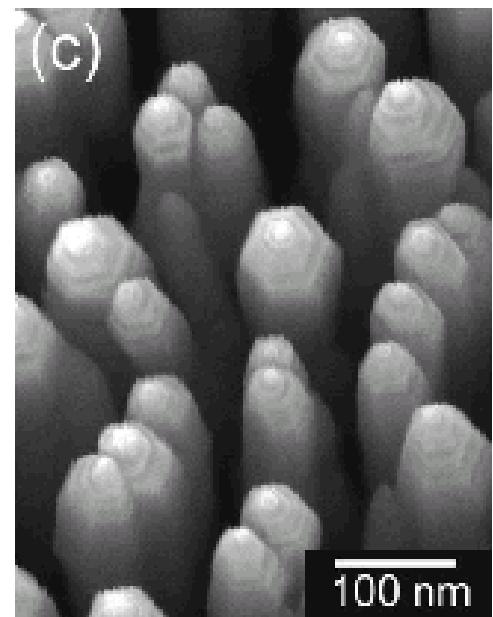
dome-shaped

半導體奈米結構之形狀

# Metalorganic vapor-phase epitaxial growth of vertically well-aligned ZnO nanorods

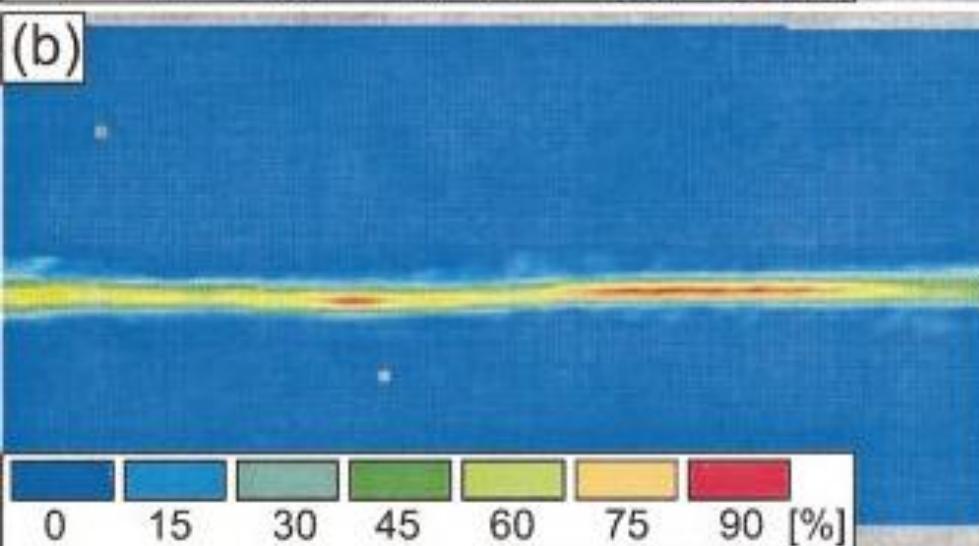
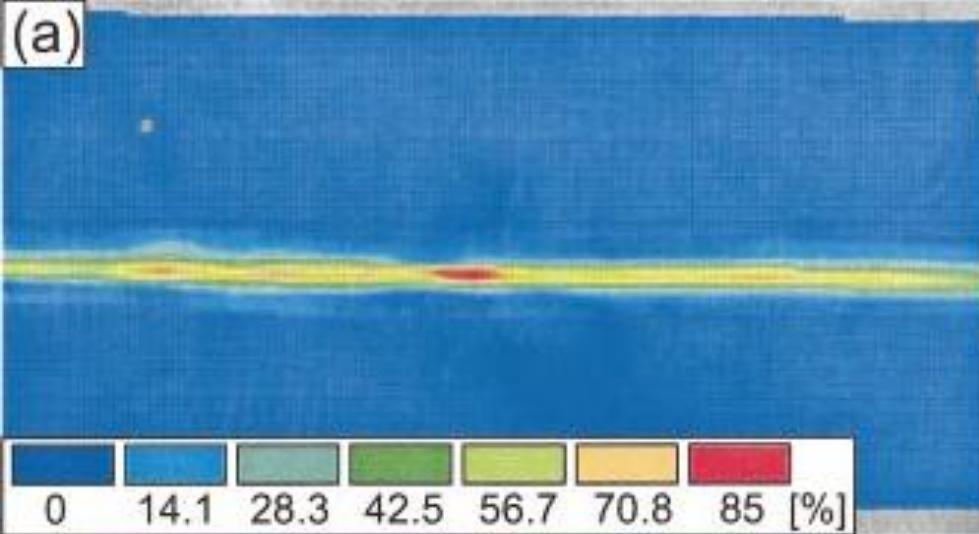


W. I. Park, D. H. Kim, S.-W. Jung, and Gyu-Chul Yi<sup>a)</sup>

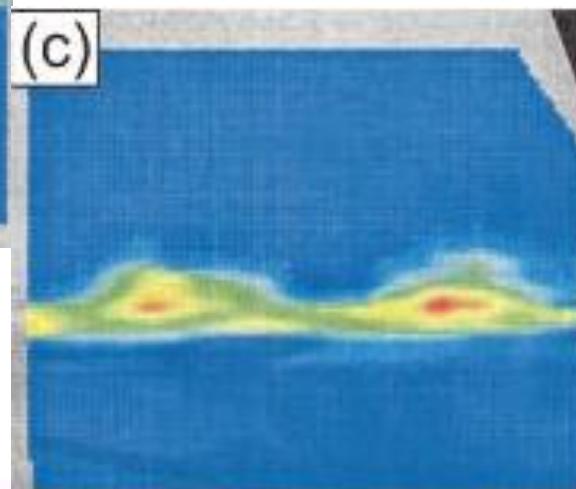


APL80, 4232 (2002)

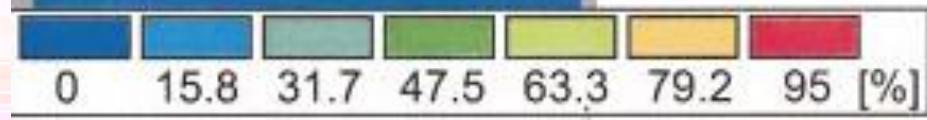
半導體奈米結構之形狀



Ref. D. Litvinov et al.  
APL 81, 640 (2002)



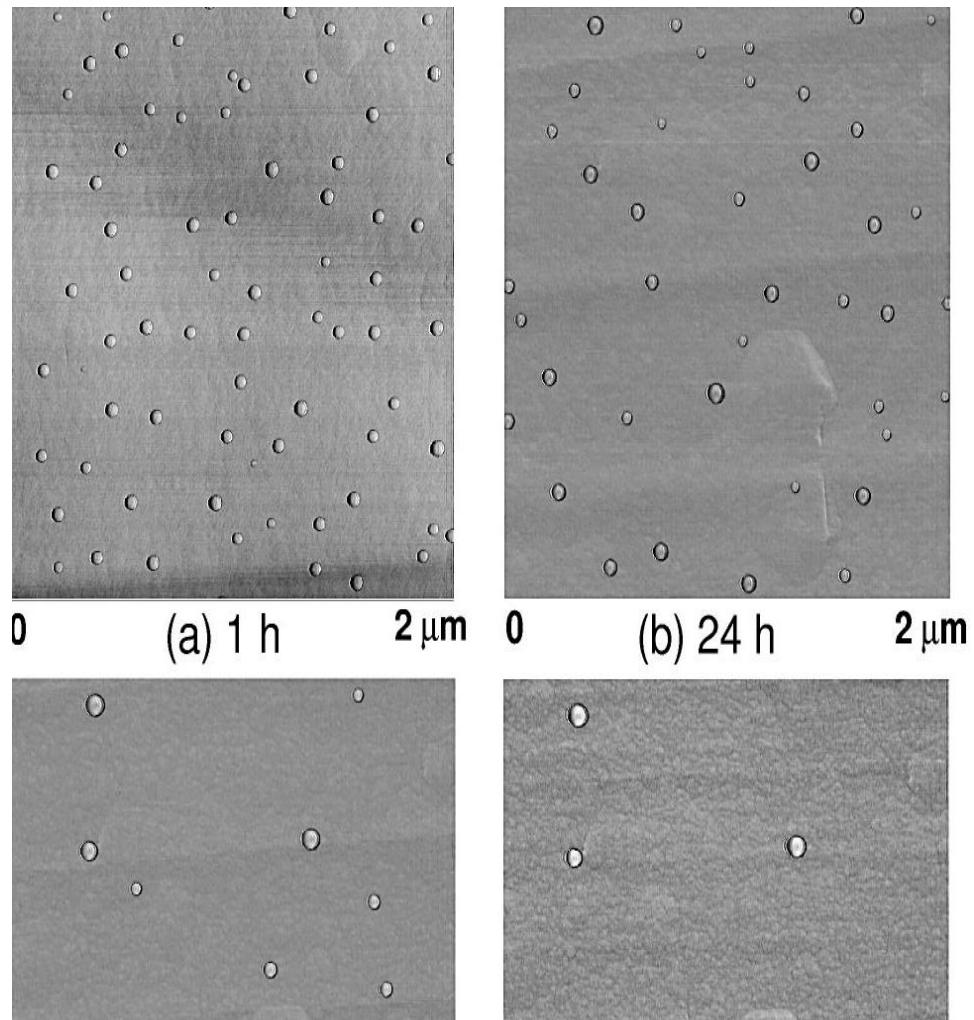
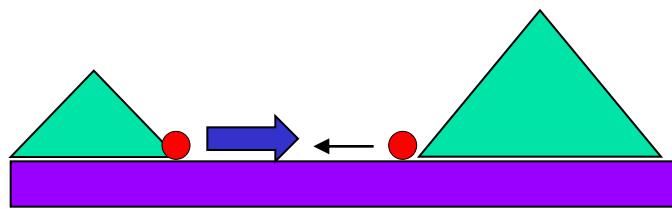
5 nm



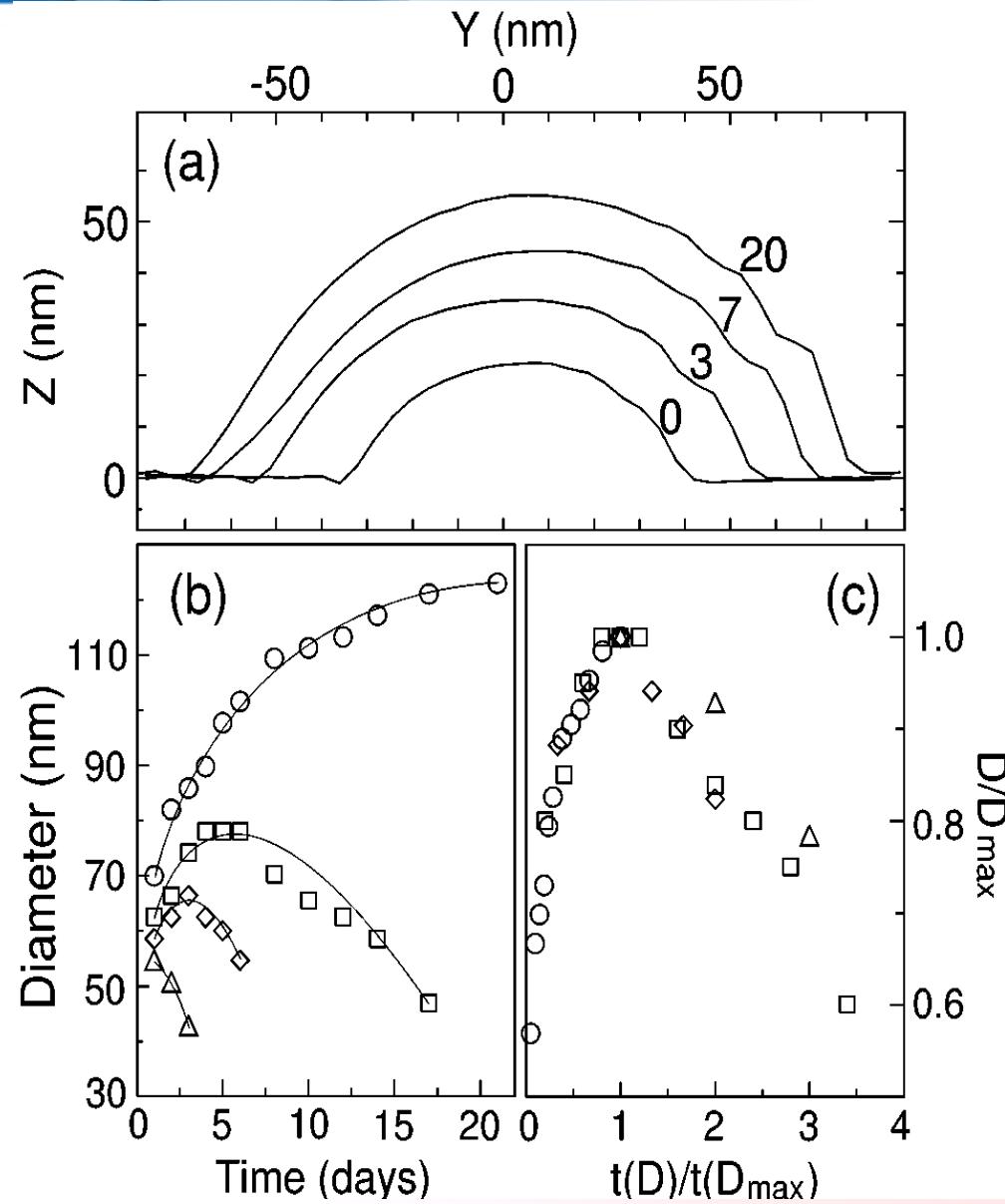


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Ref. S.Lee et al., Phys. Rev. Lett. 81, 3479 (1998)

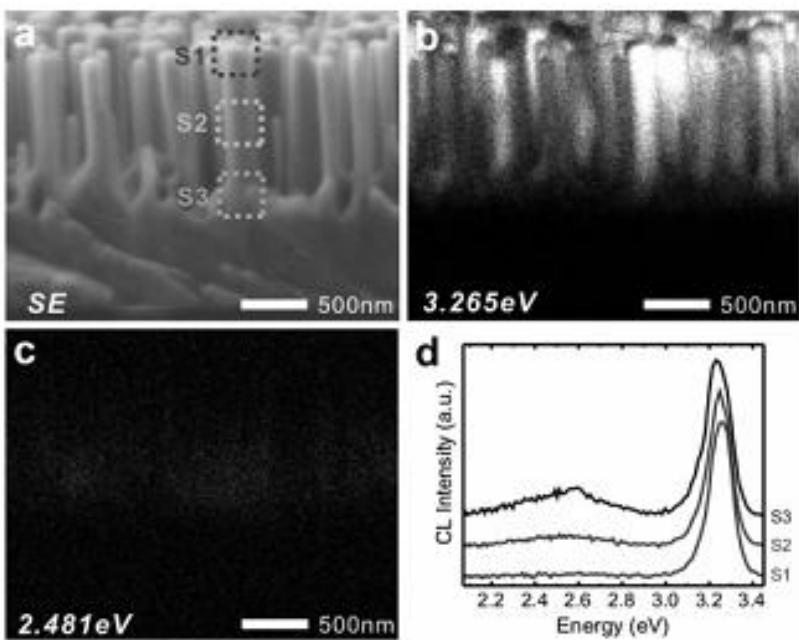
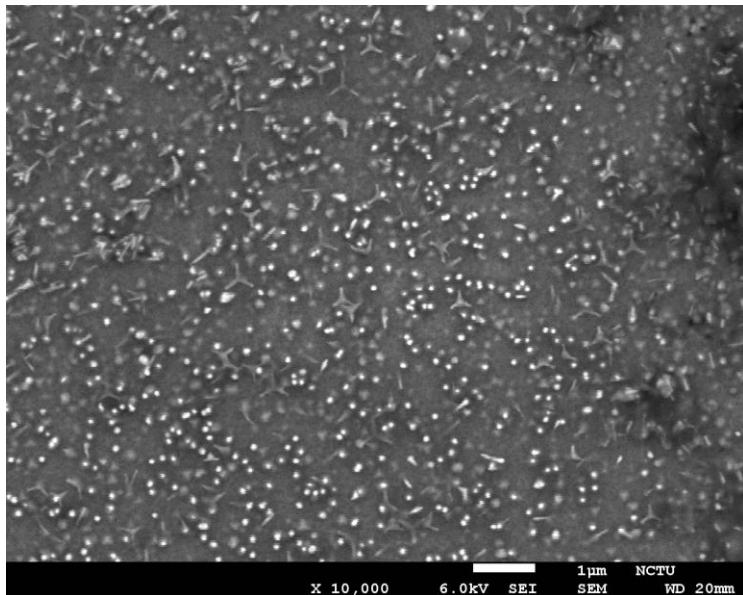
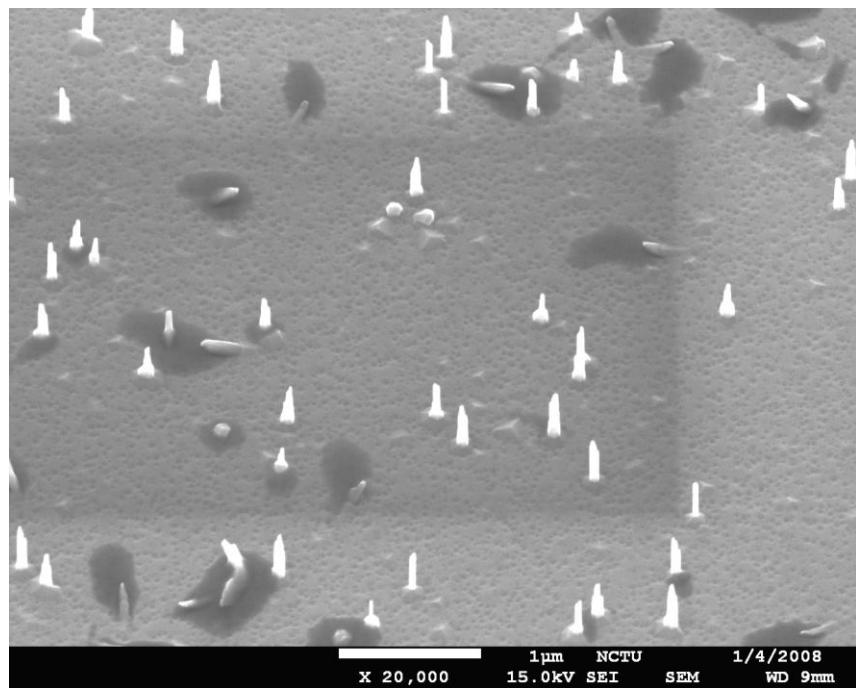


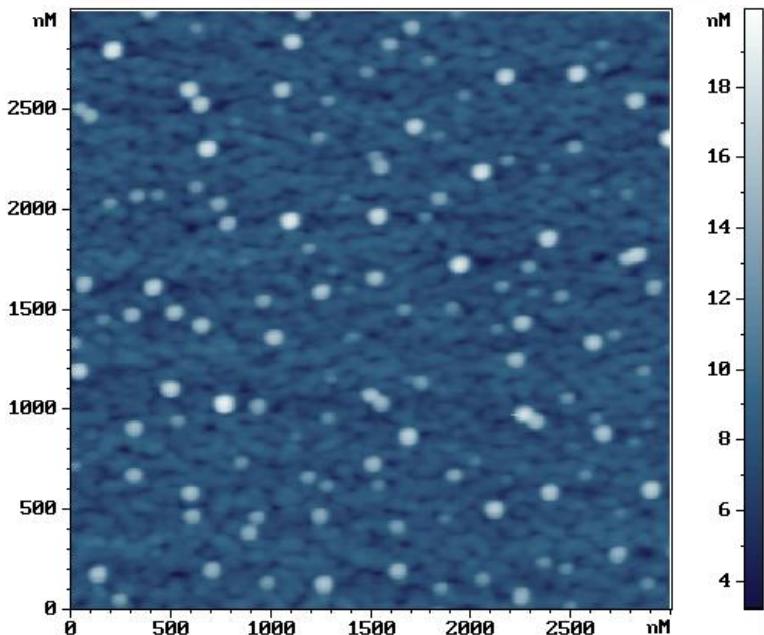


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# ZnO nano-tip





CdSe (3.0 MLs)/ZnSe/GaAs

Issue of size distribution

